

2022

**APPLIED PHYSICS**

Full Marks : 100

Time : Three hours

The figures in the margin indicate full marks for the questions.

Answer any five questions.

1. a) Write the four Maxwell's Fundamental Equations in the electromagnetic field in integral and differential form? 4
- b) Show that electromagnetic wave is transverse in nature. 5
- c) Show that electromagnetic energy is equally contributed by electric and magnetic fields equally. 5
- d) Evaluate displacement current density  $\vec{D}$  and electric field intensity  $\vec{E}$  for the given field  $\vec{H} = 0.25\epsilon_0 \cos(\omega t - 10z)\hat{a}_y$  (A/m). 6
2. a) Derive the Poynting theorem starting from Maxwell's fundamental equations in electromagnetism. 6
- b) What is the physical significance of the Poynting vector? The average intensity of the sunlight reaching the earth's surface is about  $1300 \text{ W.m}^{-2}$ . Calculate the strength of the electric field of the incoming sunlight.  $2 + 5 = 7$
- c) What is the reason for the attenuation of electromagnetic waves in a conducting medium? 2
- d) Define Skin depth. For silver the conductivity  $\sigma = 3 \times 10^7 \text{ mho.m}^{-1}$ . Find its skin depth at a frequency of 10GHz.  $2 + 3 = 5$
3. a) What is the structure of an optical fibre? 3
- b) Mention and explain briefly the different types of optical fibre. 5
- c) Write some of the applications of optical fibre and its advantages over the usage of conventional transmission lines.  $3+3 = 6$
- d) What do you mean by the Numerical Aperture of an optical fibre? 2
- e) A fibre has a refractive index of its core of 1.46 and cladding of 1.45. Compute the NA and the fractional difference in the refractive index. 4
4. a) Write short notes on attenuation, dispersion and V-parameter in the optical fibre communication system.  $2 \times 3 = 6$
- b) Explain the propagation mechanism of the light signal through an optical fibre. 4
- c) Explain the details of the optical fibre communication system with block 10

- diagrams.
5. a) What are thin films? 2  
b) Write short notes (any two): Physical Vapor Deposition (PVD), Chemical Vapor Deposition (CVD), Sputtering Technique.  $5 \times 2 = 10$   
c) Mention the usage of the following thin film characterization techniques. 5  
X-Ray Diffraction(XRD), Scanning Electron Microscope (SEM), UV/VIS Spectrometer (UV-VIS), Energy dispersive X-ray Spectroscopy (EDX), Transmission Electron Microscopy (TEM)  
d) Write some of the important applications of thin film in devices. 3
6. a) Explain the four types of polarization in the dielectric material. 8  
b) What are piezoelectric materials? Mention a few important piezoelectric materials most used.  $2 + 3 = 5$   
c) What are ferromagnetic materials? What is Curie Temperature? 4  
d) Mention some of the important applications of ferromagnetic material. 3
7. Write short notes on (any four)  $5 \times 4 = 20$   
X-Ray Diffractometer (XRD), Scanning Electron Microscopy (SEM), Transmission Electron Microscopy (TEM), Atomic Force Microscopy (AFM), Differential Scanning Calorimeter (DSC)

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